

Appl. No. 10/709,320
Amdt. Dated 11/03/2005
Reply to Office action of August 3, 2005

Amendments to the Specification:

at pages 1 and on the abstract page change the title
from

" LOW-K INTERLEVEL DIELECTRIC LAYER (ILD) AND METHOD "

to

-- LOW-K INTERLEVEL DIELECTRIC LAYER (ILD) --